



## Modern Methods for Measuring the Functional Characteristics of Surfaces

Guest Editors:

**Prof. Dr. Grzegorz Królczyk**

Department of Manufacturing Engineering and Production Automation, Faculty of Mechanical Engineering, Opole University of Technology, 5 Mikolajczyka Street, 45-271 Opole, Poland

**Prof. Dr. Richard Leach**

Manufacturing Metrology Team, Faculty of Engineering, University of Nottingham, Advanced Manufacturing Building, Jubilee Campus, Nottingham NG8 1BB, UK

**Prof. Dr. Michal Wieczorowski**

Faculty of Mechanical Engineering and Management, Poznan University of Technology, Poznan, Poland

### Message from the Guest Editors

The aim of this Special Issue is to provide an international forum for the dissemination of scientific information on surface metrology—submission from all fields involving the measurement and characterization of surface topography, including archaeology, art conservation, anthropology, biology, biomedical engineering, chemistry, civil engineering, food science, forensics, geodetics, geology, material science, mechanical engineering, manufacturing, metrology, nanotechnology, tribology, and others. The Special Issue covers the modelling, design, and characterization of surfaces and the relationship between surface properties and their applications. This Special Issue accepts high-quality articles containing original research results and review papers regarding metrology, development, and application of the science and technology of measurement, instrumentation and characterisation.

Deadline for manuscript submissions:

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### Prof. Dr. Manoj Gupta

Materials Group, Department of  
Mechanical Engineering, National  
University of Singapore, 9  
Engineering Drive 1, Singapore  
117576, Singapore

## Message from the Editor-in-Chief

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MDPI, St. Alban-Anlage 66  
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